



Advances in Remediation of Contaminated Sites: Volume II

Guest Editors:

Prof. Dr. Guining Lu

Prof. Dr. Zenghui Diao

Prof. Dr. Yaoyu Zhou

Dr. Kaibo Huang

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Message from the Guest Editors

The remediation of contaminated sites has been one of the most rapidly developing environmental research subjects. The process of the remediation of contaminated sites is a site-specific phased approach comprising site characterization, risk assessment and remediation technology selection and application. Site remediation technology has developed rapidly in recent years and has brought hope for environmental remediation. However, site remediation technology has also encountered bottlenecks and new breakthroughs are urgently required.

With the success of the previous Special Issue “Advances in Remediation of Contaminated Sites: **Volume I**”, **Volume II** of this Special Issue will continue to collect the latest progress in the remediation of contaminated sites, in order to help in solving the bottleneck in the development of site remediation technology. Topics of interest include but are not limited to:

Survey and assessment of contaminated sites;
Environmental processes and effects of pollutants;
Remediation technology and its application in
contaminated sites; Remediation strategy and
management in contaminated sites.

We look forward to receiving your contributions.





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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and
Technology, University of Turin,
Via P. Giuria 9, 10125 Turin, Italy

Message from the Editor-in-Chief

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Processes Editorial Office
MDPI, St. Alban-Anlage 66
4052 Basel, Switzerland

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